

[54] DIVING MASK

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[\*\*] Term: 14 Years

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[30] Foreign Application Priority Data

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[52] U.S. Cl. .... D29/9; D16/107

[58] Field of Search ..... D29/9; D16/102, 107; 2/12, 13, 15, 435, 444, 452, 439, 428

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[57] CLAIM

The ornamental design for a diving mask, as shown and described.

DESCRIPTION

FIG. 1 is a front and top perspective view of a diving mask showing my new design;

FIG. 2 is a front elevational view thereof;

FIG. 3 is a right side elevational view thereof, the left side view being a mirror image of that shown;

FIG. 4 is a rear elevational view thereof;

FIG. 5 is a top plan view thereof; and

FIG. 6 is a bottom plan view thereof.

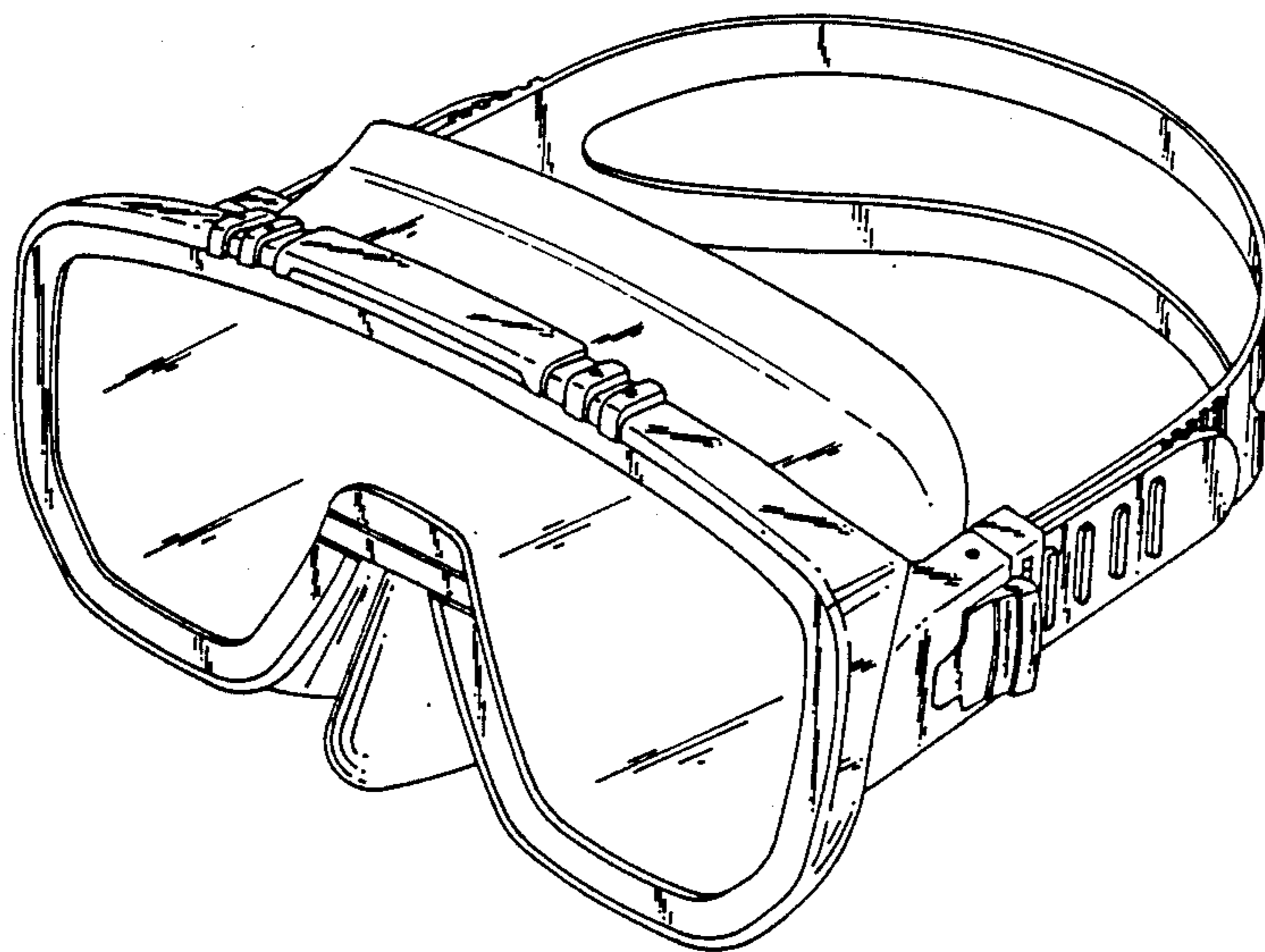


FIG. 1

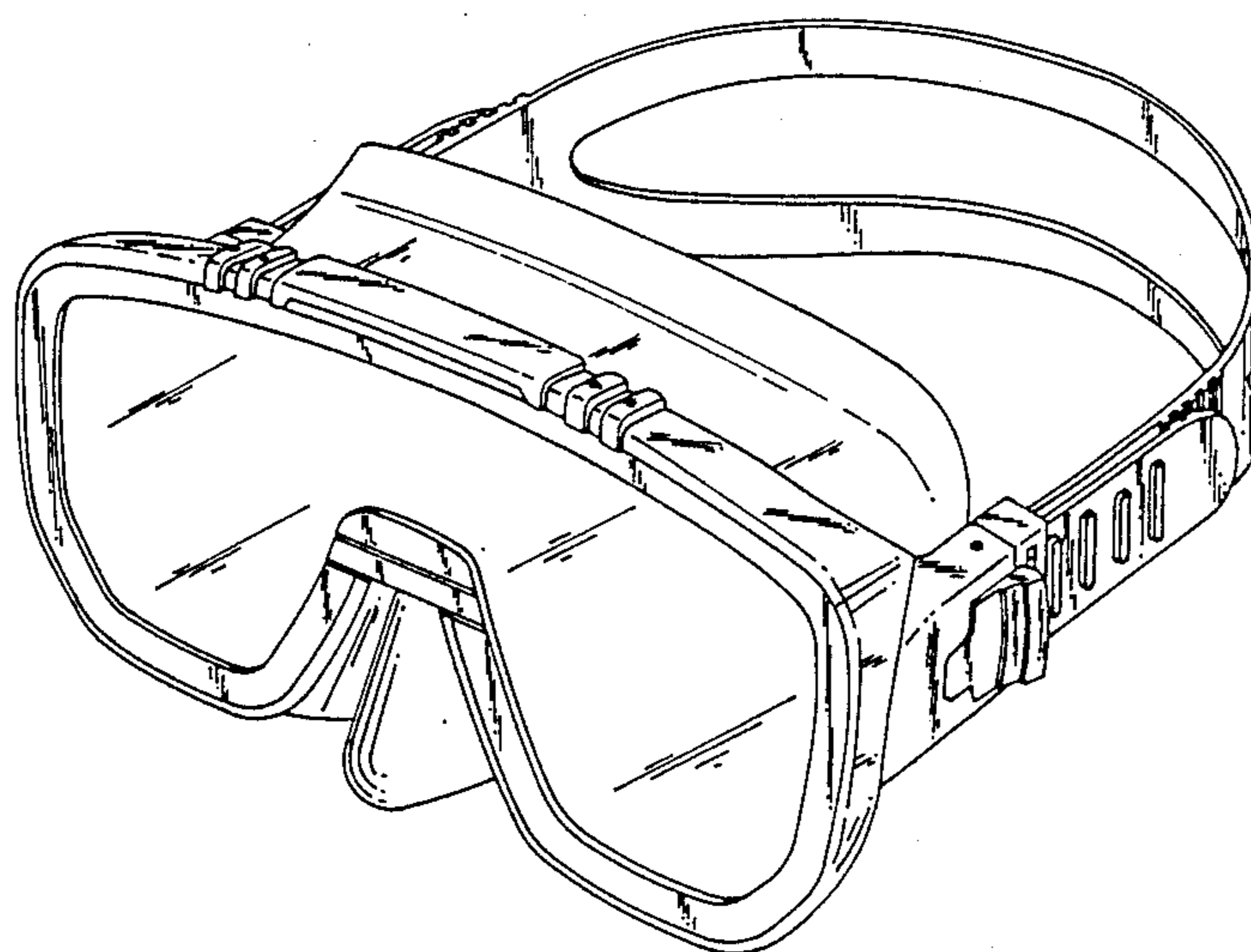


FIG. 2

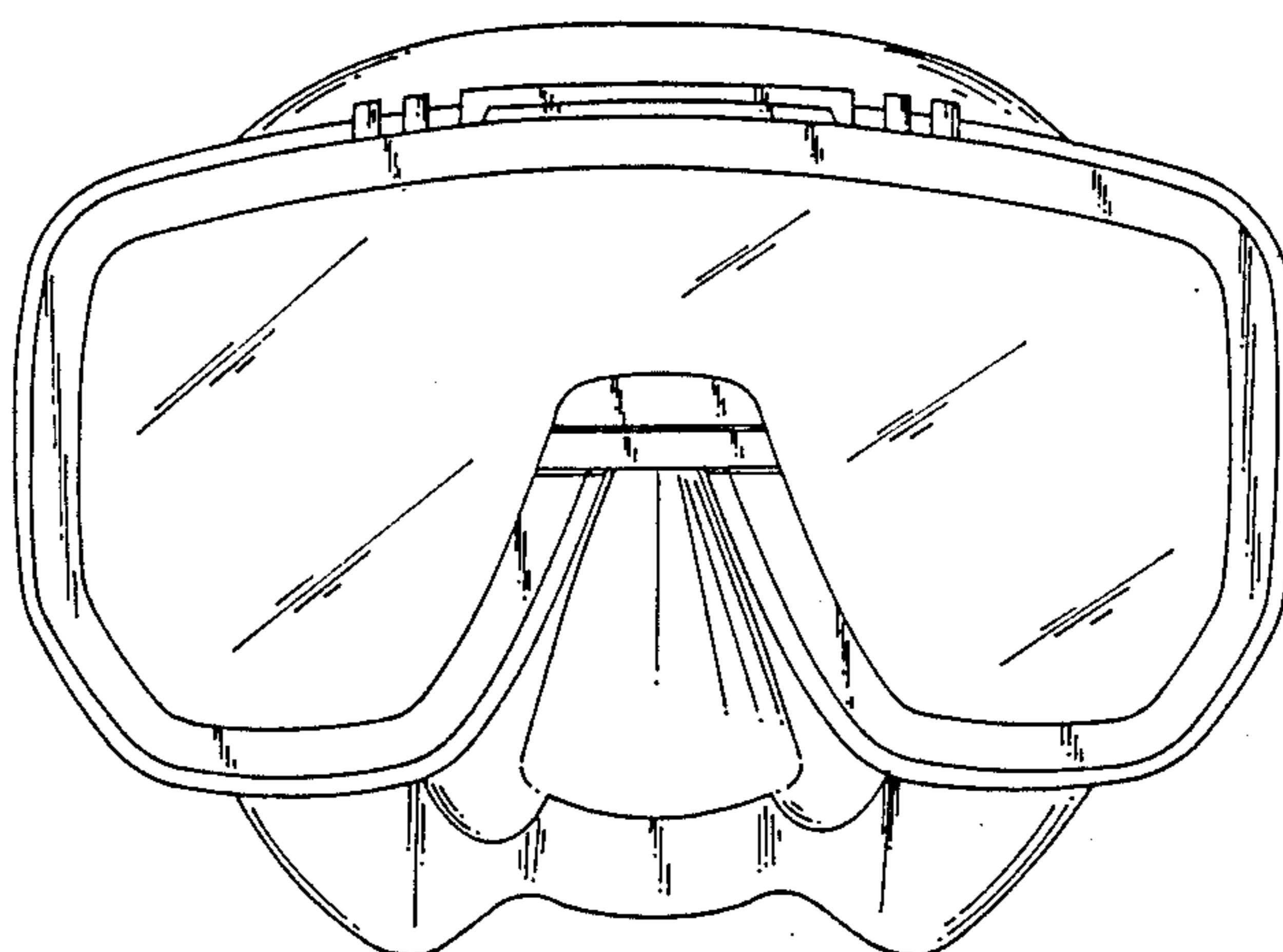


FIG. 3

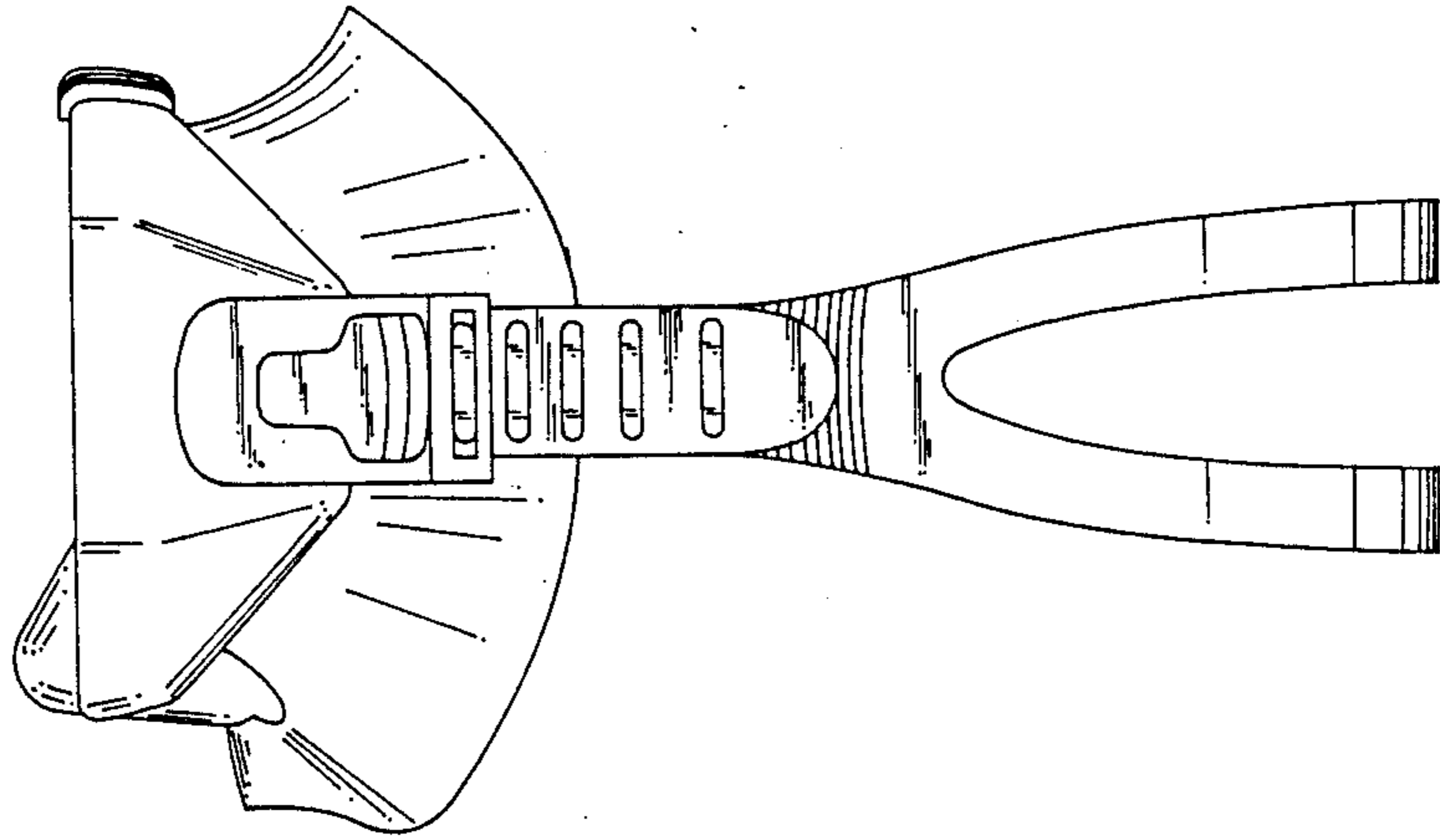


FIG. 4

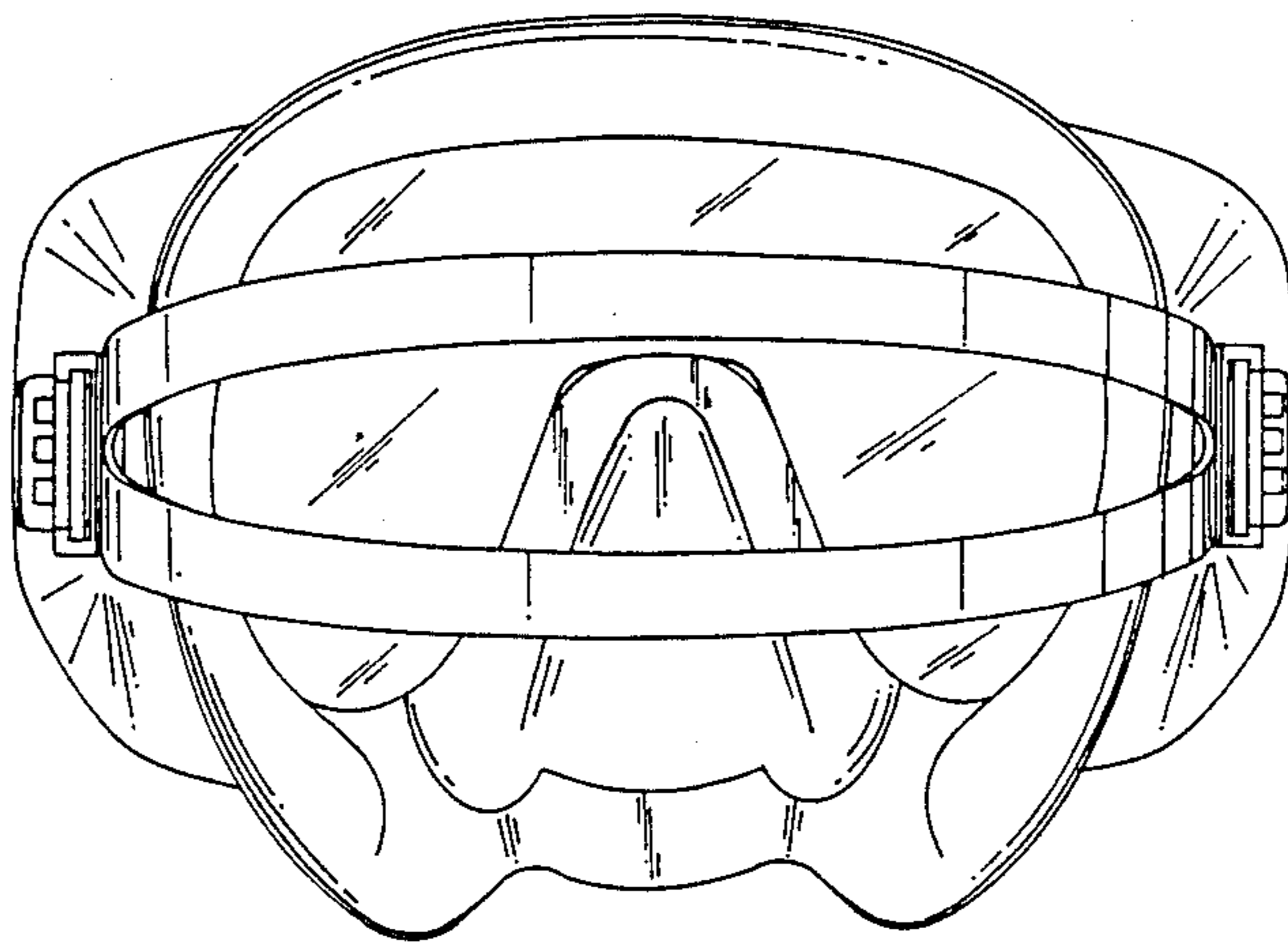


FIG. 5

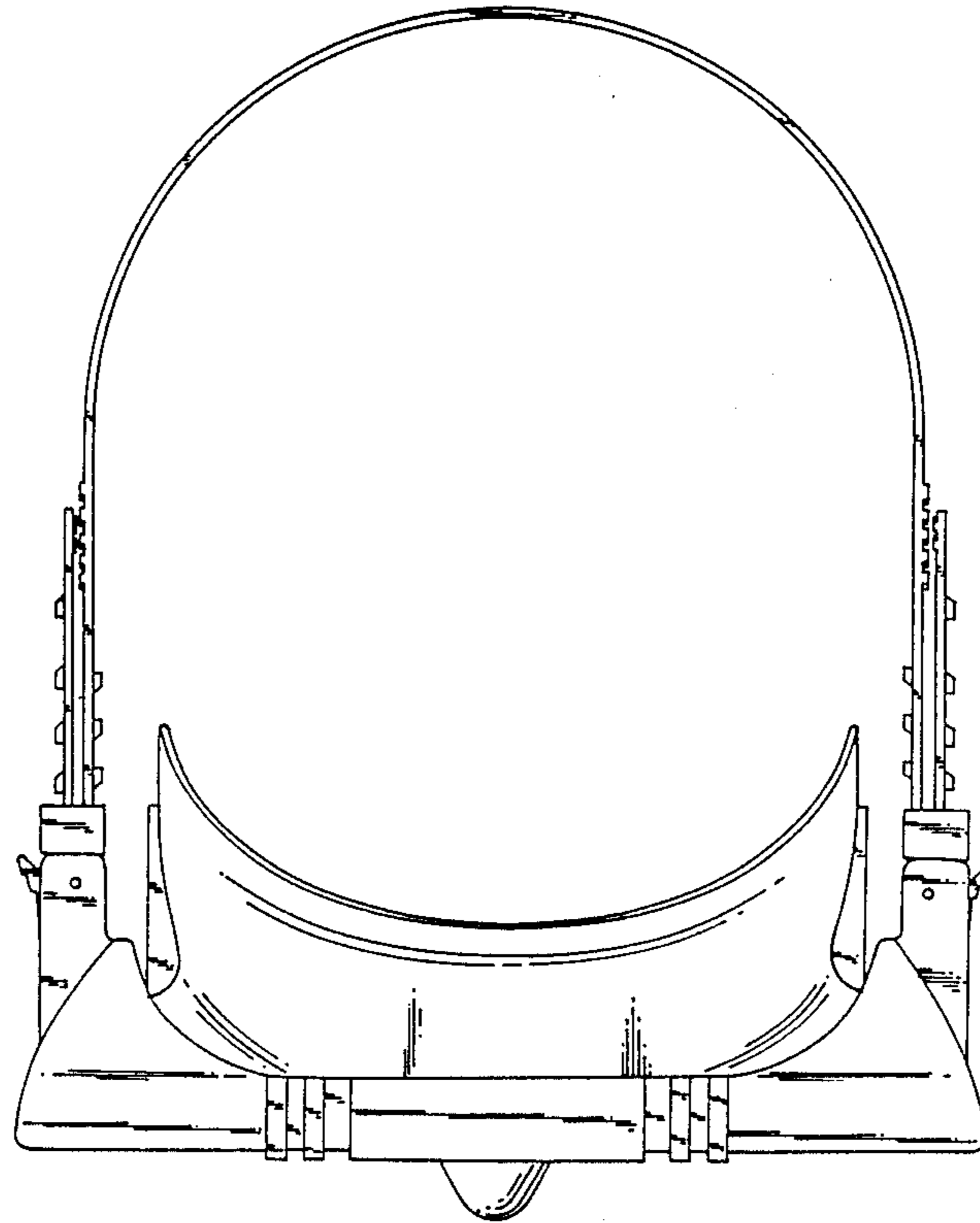


FIG. 6

